## Shoou Jinn Chang

List of Publications by Year in descending order

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327 papers 4,681 citations

36 h-index 52 g-index

330 all docs 330 does citations

330 times ranked 4831 citing authors

#	Article	IF	CITATIONS
1	Highly sensitive ZnO nanowire CO sensors with the adsorption of Au nanoparticles. Nanotechnology, 2008, 19, 175502.	2.6	194
2	A New Tri-Band Bandpass Filter Based on Stub-Loaded Step-Impedance Resonator. IEEE Microwave and Wireless Components Letters, 2012, 22, 179-181.	3.2	119
3	InGaN-AllnGaN multiquantum-well LEDs. IEEE Photonics Technology Letters, 2001, 13, 559-561.	2.5	100
4	Electroluminescence from n-ZnO nanowires/p-GaN heterostructure light-emitting diodes. Applied Physics Letters, 2009, 95, .	3.3	99
5	High Sensitivity of NO Gas Sensors Based on Novel Ag-Doped ZnO Nanoflowers Enhanced with a UV Light-Emitting Diode. ACS Omega, 2018, 3, 13798-13807.	3.5	92
6	Nitride-Based High-Power Flip-Chip LED With Double-Side Patterned Sapphire Substrate. IEEE Photonics Technology Letters, 2007, 19, 780-782.	2.5	75
7	Terahertz temperature-dependent defect mode in a semiconductor-dielectric photonic crystal. Journal of Applied Physics, 2011, 110, .	2.5	72
8	High detectivity InGaN-GaN multiquantum well p-n junction photodiodes. IEEE Journal of Quantum Electronics, 2003, 39, 681-685.	1.9	67
9	High responsivity of amorphous indium gallium zinc oxide phototransistor with Ta2O5 gate dielectric. Applied Physics Letters, 2012, 101, .	3.3	67
10	A High-Responsivity GaN Nanowire UV Photodetector. IEEE Journal of Selected Topics in Quantum Electronics, 2011, 17, 996-1001.	2.9	62
11	ZnO Branched Nanowires and the p-CuO/n-ZnO Heterojunction Nanostructured Photodetector. IEEE Nanotechnology Magazine, 2013, 12, 263-269.	2.0	62
12	A Lateral ZnO Nanowire Photodetector Prepared on Glass Substrate. Journal of the Electrochemical Society, 2010, 157, K30.	2.9	61
13	ZnO Nanowire-Based Oxygen Gas Sensor. IEEE Sensors Journal, 2009, 9, 485-489.	4.7	58
14	Surface Characteristics, Optical and Electrical Properties on Sol-Gel Synthesized Sn-Doped ZnO Thin Film. Materials Transactions, 2010, 51, 1340-1345.	1.2	57
15	Tunable UV- and Visible-Light Photoresponse Based on p-ZnO Nanostructures/n-ZnO/Glass Peppered with Au Nanoparticles. ACS Applied Materials & Samp; Interfaces, 2017, 9, 14935-14944.	8.0	57
16	Automated passive filter synthesis using a novel tree representation and genetic programming. IEEE Transactions on Evolutionary Computation, 2006, 10, 93-100.	10.0	55
17	Amorphous InGaZnO ultraviolet phototransistors with double-stack Ga2O3/SiO2 dielectric. Applied Physics Letters, 2013, 102, .	3.3	54
18	Fabrication and Characterization of Coaxial p-Copper Oxide/n-ZnO Nanowire Photodiodes. IEEE Nanotechnology Magazine, 2012, 11, 127-133.	2.0	52

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19	High quality ZnO thin films on InP substrates prepared by radio frequency magnetron sputtering. II. Surface acoustic wave device fabrication. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 1995, 13, 385-388.	2.1	50
20	GaN-Based Light-Emitting Diode With Sputtered AlN Nucleation Layer. IEEE Photonics Technology Letters, 2012, 24, 294-296.	2.5	49
21	Vertical Single-Crystal ZnO Nanowires Grown on ZnO : Ga/Glass Templates. IEEE Nanotechnology Magazine, 2005, 4, 649-654.	2.0	47
22	A ZnO nanowire vacuum pressure sensor. Nanotechnology, 2008, 19, 095505.	2.6	47
23	A Solar-Blind \$eta\$-Ga\$_2\$O\$_3\$ Nanowire Photodetector. IEEE Photonics Technology Letters, 2010, 22, 709-711.	2.5	47
24	Electrical and Optical Characteristics of UV Photodetector With Interlaced ZnO Nanowires. IEEE Journal of Selected Topics in Quantum Electronics, 2011, 17, 990-995.	2.9	45
25	CuO Nanowire-Based Humidity Sensor. IEEE Sensors Journal, 2012, 12, 1884-1888.	4.7	44
26	Design of a Compact Ultra-Wideband Bandpass Filter With an Extremely Broad Stopband Region. IEEE Microwave and Wireless Components Letters, 2016, 26, 392-394.	3.2	44
27	Electrostatic studies of π–π interaction for benzene stacking on a graphene layer. Applied Physics Letters, 2011, 99, .	3.3	41
28	A Visible-Blind TiO2Nanowire Photodetector. Journal of the Electrochemical Society, 2012, 159, J132-J135.	2.9	41
29	Amorphous Indium–Gallium–Oxide UV Photodetectors. IEEE Photonics Technology Letters, 2015, 27, 2083-2086.	2.5	41
30	Bandgap-Engineered in Indium–Gallium–Oxide Ultraviolet Phototransistors. IEEE Photonics Technology Letters, 2015, 27, 915-918.	2.5	41
31	Growth of Ga $_{m 2}$ 0 $_{m 3}$ Nanowires and the Fabrication of Solar-Blind Photodetector. IEEE Nanotechnology Magazine, 2011, 10, 1047-1052.	2.0	40
32	$m = 12\$ Nanowire Photodetector Prepared on $m = 12\$ Template. IEEE Sensors Journal, 2013, 13, 2368-2373.	4.7	40
33	Field-Emission and Photoelectrical Characteristics of Ga–ZnO Nanorods Photodetector. IEEE Transactions on Electron Devices, 2013, 60, 1905-1910.	3.0	39
34	GaN MSM UV Photodetector With Sputtered AlN Nucleation Layer. IEEE Sensors Journal, 2015, 15, 4743-4748.	4.7	37
35	Carbon Nanotubes With Adsorbed Au for Sensing Gas. IEEE Sensors Journal, 2013, 13, 2423-2427.	4.7	36
36	A WO <sub>3</sub> Nanoparticles NO Gas Sensor Prepared by Hot-Wire CVD. IEEE Electron Device Letters, 2017, 38, 266-269.	3.9	36

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37	Ultraviolet/Visible Photodetectors Based on p–n NiO/ZnO Nanowires Decorated with Pd Nanoparticles. ACS Applied Nano Materials, 2019, 2, 6343-6351.	5.0	36
38	Inserting a p-InGaN layer before the p-AlGaN electron blocking layer suppresses efficiency droop in InGaN-based light-emitting diodes. Applied Physics Letters, 2012, 101, 081120.	3.3	35
39	Transparent ZnO-nanowire-based device for UV light detection and ethanol gas sensing on c-Si solar cell. RSC Advances, 2016, 6, 11146-11150.	3.6	35
40	Improved Performance of GaN-Based Blue LEDs With the InGaN Insertion Layer Between the MQW Active Layer and the n-GaN Cladding Layer. IEEE Journal of Quantum Electronics, 2010, 46, 513-517.	1.9	34
41	Visible-Blind Photodetectors With Mg-Doped ZnO Nanorods. IEEE Photonics Technology Letters, 2014, 26, 645-648.	2.5	34
42	Gallium nitride metal-semiconductor-metal photodetectors prepared on silicon substrates. Journal of Applied Physics, 2007, 102, .	2.5	32
43	\${m Ga}_{2}{m O}_{3}\$/AlGaN/GaN Heterostructure Ultraviolet Three-Band Photodetector. IEEE Sensors Journal, 2013, 13, 3462-3467.	4.7	32
44	A \$eta\$-Ga\$_{2}\$O\$_{3}\$/GaN Schottky-Barrier Photodetector. IEEE Photonics Technology Letters, 2011, 23, 444-446.	2.5	28
45	ZnO nanowires modified with Au nanoparticles for nonenzymatic amperometric sensing of glucose. Applied Physics Letters, 2014, 104, .	3.3	28
46	The properties of photo chemical-vapor deposition SiO2 and its application in GaN metal-insulator semiconductor ultraviolet photodetectors. Journal of Electronic Materials, 2003, 32, 395-399.	2.2	27
47	Nonenzymatic Glucose Sensor Based on Au/ZnO Core–Shell Nanostructures Decorated with Au Nanoparticles and Enhanced with Blue and Green Light. Journal of Physical Chemistry B, 2017, 121, 2931-2941.	2.6	27
48	Fast Detection and Flexible Microfluidic pH Sensors Based on Al-Doped ZnO Nanosheets with a Novel Morphology. ACS Omega, 2019, 4, 19847-19855.	3.5	27
49	UV Enhanced Field Emission Performance of Mg-Doped ZnO Nanorods. IEEE Transactions on Electron Devices, 2014, 61, 1541-1545.	3.0	26
50	High Density Novel Porous ZnO Nanosheets Based on a Microheater Chip for Ozone Sensors. IEEE Sensors Journal, 2018, 18, 5559-5565.	4.7	26
51	GaN-Based LEDs With a Chirped Multiquantum Barrier Structure. IEEE Photonics Technology Letters, 2012, 24, 1600-1602.	2.5	25
52	Simple method to design a tri-band bandpass filter using asymmetric SIRs for GSM, WIMAX, and WLAN applications. Microwave and Optical Technology Letters, 2011, 53, 1573-1576.	1.4	24
53	A Flexible ZnO Nanowire-Based Humidity Sensor. IEEE Nanotechnology Magazine, 2012, 11, 520-525.	2.0	24
54	Low-Frequency Noise Characteristics of In-Doped ZnO Ultraviolet Photodetectors. IEEE Photonics Technology Letters, 2013, 25, 2043-2046.	2.5	24

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55	Optimization of the dye-sensitized solar cell performance by mechanical compression. Nanoscale Research Letters, 2014, 9, 523.	5.7	24
56	Nitride-Based Light Emitting Diodes With Textured Sidewalls and Pillar Waveguides. IEEE Photonics Technology Letters, 2006, 18, 2517-2519.	2.5	23
57	Deep UV \${m Ta}_{2}{m O}_{5}\$/Zinc-Indium-Tin-Oxide Thin Film Photo-Transistor. IEEE Photonics Technology Letters, 2012, 24, 1018-1020.	2.5	23
58	Photoelectrical and Low-Frequency Noise Characteristics of ZnO Nanorod Photodetectors Prepared on Flexible Substrate. IEEE Transactions on Electron Devices, 2013, 60, 229-234.	3.0	23
59	High Responsivity MgZnO Ultraviolet Thin-Film Phototransistor Developed Using Radio Frequency Sputtering. Materials, 2017, 10, 126.	2.9	23
60	Low-Noise and High-Detectivity GaN UV Photodiodes With a Low-Temperature AlN Cap Layer. IEEE Sensors Journal, 2007, 7, 1289-1292.	4.7	22
61	InGaN/GaN light-emitting diodes with a reflector at the backside of sapphire substrates. Journal of Electronic Materials, 2003, 32, 403-406.	2.2	21
62	A $\pm -\frac{2}{m Ga}_{2} \ m O}_{3}\ /GaN \ Hetero-Structured Solar-Blind and Visible-Blind Dual-Band Photodetector. IEEE Sensors Journal, 2011, 11, 1491-1492.$	4.7	21
63	ZnO-Nanowire-Based Extended-Gate Field-Effect-Transistor pH Sensors Prepared on Glass Substrate. Science of Advanced Materials, 2012, 4, 1174-1178.	0.7	21
64	Integration of bandgap-engineered double-stacked channel layers with nitrogen doping for high-performance InGaO TFTs. Applied Physics Letters, 2019, $114$ , .	3.3	20
65	Nitride-Based LEDs With High-Reflectance and Wide-Angle Ag Mirror\${+}\$SiO\$_{2}\$/TiO\$_{2}\$ DBR Backside Reflector. Journal of Lightwave Technology, 2011, 29, 1033-1038.	4.6	19
66	Influences of surface reconstruction on the atomic-layer-deposited HfO2/Al2O3/n-InAs metal-oxide-semiconductor capacitors. Applied Physics Letters, 2011, 98, 123509.	3.3	19
67	Surface plasmon-enhanced gas sensing in single gold-peapodded silica nanowires. NPG Asia Materials, 2013, 5, e49-e49.	7.9	19
68	Noise Characteristics of ZnO-Nanowire Photodetectors Prepared on ZnO:Ga/Glass Templates. IEEE Sensors Journal, 2007, 7, 1020-1024.	4.7	18
69	Highly Reliable High-Brightness GaN-Based Flip Chip LEDs. IEEE Transactions on Advanced Packaging, 2007, 30, 752-757.	1.6	18
70	An $\{(m A]_{m x}_{m Ga}_{1-\{m x\}})\}_{2}\{m O\}_{3}$ \$ Metal-Semiconductor-Metal VUV Photodetector. IEEE Sensors Journal, 2011, 11, 1795-1799.	4.7	18
71	\${m Ga}_{2}{m O}_{3}\$/GaN-Based Metal-Semiconductor-Metal Photodetectors Covered With Au Nanoparticles. IEEE Photonics Technology Letters, 2013, 25, 1809-1811.	2.5	18
72	Improved Field Emission Properties of Ag-Decorated Multi-Walled Carbon Nanotubes. IEEE Photonics Technology Letters, 2013, 25, 1017-1019.	2.5	18

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73	High Responsivity Mg <sub>x</sub> Zn <sub>1â^'x</sub> O Film UV Photodetector Grown by RF Sputtering. IEEE Photonics Technology Letters, 2015, 27, 978-981.	2.5	18
74	Effects of humidity and ultraviolet characteristics on $\hat{l}^2$ -Ga <sub>2</sub> O <sub>3</sub> nanowire sensor. RSC Advances, 2015, 5, 84776-84781.	3.6	18
75	Thin-Film Transistors With Amorphous Indium–Gallium-Oxide Bilayer Channel. IEEE Electron Device Letters, 2017, 38, 572-575.	3.9	18
76	Studies of polymer ball type polymer dispersed liquid crystal films. Liquid Crystals, 1996, 21, 19-23.	2.2	17
77	AlGaN/GaN metal-oxide semiconductor heterostructure field-effect transistor with photo-chemical-vapor deposition SiO2 gate oxide. Journal of Electronic Materials, 2003, 32, 407-410.	2.2	17
78	Flicker noise of GaN-based heterostructure field-effect transistors with Si-doped AlGaN carrier injection layer. IEEE Electron Device Letters, 2003, 24, 622-624.	3.9	17
79	Enhanced Field Electron Emission From Zinc-Doped CuO Nanowires. IEEE Electron Device Letters, 2012, 33, 887-889.	3.9	17
80	Photo-Electrical Properties of MgZnO Thin-Film Transistors With High- \${k}\$ Dielectrics. IEEE Photonics Technology Letters, 2018, 30, 59-62.	2.5	17
81	Electrical Properties of Indium Aluminum Zinc Oxide Thin Film Transistors. Journal of Electronic Materials, 2018, 47, 6923-6928.	2.2	17
82	High quality ZnO thin films on InP substrates prepared by radio frequency magnetron sputtering. I. Material study. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 1995, 13, 381-384.	2.1	16
83	High-Detectivity Nitride-Based MSM Photodetectors on InGaN–GaN Multiquantum Well With the Unactivated Mg-Doped GaN Layer. IEEE Journal of Quantum Electronics, 2007, 43, 1060-1064.	1.9	16
84	CuO-Nanowire Field Emitter Prepared on Glass Substrate. IEEE Nanotechnology Magazine, 2011, 10, 1161-1165.	2.0	16
85	InGaN/GaN Multiquantum-Well Metal-Semiconductor-Metal Photodetectors With Beta-\${m Ga}_{2}{m O}_{3}\$ Cap Layers. IEEE Sensors Journal, 2013, 13, 1187-1191.	4.7	16
86	Noise Properties of Fe-ZnO Nanorod Ultraviolet Photodetectors. IEEE Photonics Technology Letters, 2013, 25, 2089-2092.	2.5	16
87	GaN-Based Ultraviolet Light Emitting Diodes With Ex Situ Sputtered AlN Nucleation Layer. Journal of Display Technology, 2013, 9, 895-899.	1.2	16
88	Synthesis of CuInS2 quantum dots using polyetheramine as solvent. Nanoscale Research Letters, 2015, 10, 122.	5.7	16
89	GaN-Based Power LEDs With CMOS ESD Protection Circuits. IEEE Transactions on Device and Materials Reliability, 2007, 7, 340-346.	2.0	15
90	Low-Noise and High-Detectivity GaN-Based UV Photodiode With a Semi-Insulating Mg-Doped GaN Cap Layer. IEEE Sensors Journal, 2007, 7, 1270-1273.	4.7	15

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91	High quality GaN-based Schottky barrier diodes. Applied Physics Letters, 2008, 93, 132110.	3.3	15
92	Photoconductive Gain of Vertical ZnO Nanorods on Flexible Polyimide Substrate by Low-Temperature Process. IEEE Sensors Journal, 2011, 11, 3457-3461.	4.7	15
93	GaNâ€based Schottky barrier ultraviolet photodetector with a 5â€pair AlGaN–GaN intermediate layer. Physica Status Solidi (A) Applications and Materials Science, 2012, 209, 579-584.	1.8	15
94	Oxygen Partial Pressure Impact on Characteristics of Indium Titanium Zinc Oxide Thin Film Transistor Fabricated via RF Sputtering. Nanomaterials, 2017, 7, 156.	4.1	15
95	Indium Gallium Oxide Thin Film Transistor for Two-Stage UV Sensor Application. ECS Journal of Solid State Science and Technology, 2019, 8, Q3140-Q3143.	1.8	15
96	SiGe heterostructure field-effect transistor using V-shaped confining potential well. IEEE Electron Device Letters, 2003, 24, 69-71.	3.9	14
97	Characterization of AlGaN/GaN Metal- Semiconductor-Metal Photodetectors With a Low-Temperature AlGaN Interlayer. IEEE Sensors Journal, 2009, 9, 723-727.	4.7	14
98	AlGaN/GaN Schottky Barrier Photodetector With Multi- $fm Mg$ _{m x} {m N} _{m y} \$/GaN Buffer. IEEE Sensors Journal, 2009, 9, 87-92.	4.7	14
99	Optoelectronic Characteristics of UV Photodetector Based on ZnO Nanopillar Thin Films Prepared by Sol-Gel Method. Materials Transactions, 2009, 50, 922-925.	1.2	14
100	An investigation of the microstructure, optical and electrical properties of ZITO thin film using the sol–gel method. Journal of Sol-Gel Science and Technology, 2010, 54, 347-354.	2.4	14
101	Investigating the Effect of Piezoelectric Polarization on GaN-Based LEDs With Different Quantum Barrier Thickness. Journal of Display Technology, 2013, 9, 206-211.	1.2	14
102	Two-dimensional ZnO nanowalls for gas sensor and photoelectrochemical applications. Electronic Materials Letters, 2014, 10, 693-697.	2.2	14
103	Amorphous InGaZnO Ultraviolet Phototransistors With a Thin Ga <sub>2</sub> O <sub>3</sub> Layer. IEEE Journal of Selected Topics in Quantum Electronics, 2014, 20, 125-129.	2.9	14
104	A Simple and Effective Method for Designing Frequency Adjustable Balun Diplexer With High Common-Mode Suppression. IEEE Microwave and Wireless Components Letters, 2015, 25, 433-435.	3.2	14
105	Effect of Oxygen Vacancy Ratio on a GaZTO Solar-Blind Photodetector. Coatings, 2018, 8, 293.	2.6	14
106	Introduction to a New Journal: Applied System Innovation. Applied System Innovation, 2018, 1, 1.	4.6	14
107	A Bifacial SnO <sub>2</sub> Thin-Film Ethanol Gas Sensor. IEEE Electron Device Letters, 2018, 39, 1223-1225.	3.9	14
108	Design of Dual-Band Bandpass Filter With Simultaneous Narrow- and Wide-Bandwidth and a Wide Stopband. IEEE Access, 2019, 7, 147694-147703.	4.2	14

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109	AlGalnP-sapphire glue bonded light-emitting diodes. IEEE Journal of Quantum Electronics, 2002, 38, 1390-1394.	1.9	13
110	Enhanced CMOS performances using substrate strained-SiGe and mechanical strained-Si technology. IEEE Electron Device Letters, 2006, 27, 46-48.	3.9	13
111	Crabwise ZnO Nanowire UV Photodetector Prepared on ZnO : Ga/Glass Template. IEEE Nanotechnology Magazine, 2007, 6, 595-600.	2.0	13
112	The Optimized Geometry of the SiGe HBT Power Cell for 802.11a WLAN Applications. IEEE Microwave and Wireless Components Letters, 2007, 17, 49-51.	3.2	13
113	Improved Carrier Distributions by Varying Barrier Thickness for InGaN/GaN LEDs. Journal of Display Technology, 2013, 9, 239-243.	1.2	13
114	Dark Currents in HgCdTe Photodiodes Passivated with ZnS/CdS. Journal of the Electrochemical Society, 1999, 146, 1540-1545.	2.9	12
115	The Effect of Geometry on the Noise Characterization of SiGe HBTs and Optimized Device Sizes for the Design of Low-Noise Amplifiers. IEEE Transactions on Microwave Theory and Techniques, 2004, 52, 2153-2162.	4.6	12
116	Nitride-based LEDs with MQW active regions grown by different temperature profiles. IEEE Photonics Technology Letters, 2005, 17, 1806-1808.	2.5	12
117	High-Brightness InGaN–GaN Power Flip-Chip LEDs. Journal of Lightwave Technology, 2009, 27, 1985-1989.	4.6	12
118	AlGaN/GaN Schottky Barrier UV Photodetectors With a GaN Sandwich Layer. IEEE Sensors Journal, 2009, 9, 814-819.	4.7	12
119	Impact of stress-memorization technique induced-tensile strain on low frequency noise in n-channel metal-oxide-semiconductor transistors. Applied Physics Letters, 2010, 97, 123501.	3.3	12
120	AlGaN/GaN high electron mobility transistors based on InGaN/GaN multiquantum-well structures. Applied Physics Letters, 2010, 96, .	3.3	12
121	Effect of Growth Pressure of Undoped GaN Layer on the ESD Characteristics of GaN-Based LEDs Grown on Patterned Sapphire. IEEE Photonics Technology Letters, 2011, 23, 968-970.	2.5	12
122	InGaP/GaAs/Ge tripleâ€junction solar cells with ZnO nanowires. Progress in Photovoltaics: Research and Applications, 2013, 21, 1645-1652.	8.1	12
123	UV Enhanced Indium-Doped ZnO Nanorod Field Emitter. IEEE Transactions on Electron Devices, 2013, 60, 3901-3906.	3.0	12
124	Highly stable ITO/Zn2TiO4/Pt resistive random access memory and its application in two-bit-per-cell. RSC Advances, 2018, 8, 17622-17628.	3.6	12
125	High-Speed InGaAs P-I-N Photodetector With Planar Buried Heterostructure. IEEE Transactions on Electron Devices, 2009, 56, 1347-1350.	3.0	11
126	A Deep UV Sensitive ${m Ta}_{2}{m O}_{5}/{m a-IGZO}$ TFT. IEEE Sensors Journal, 2011, 11, 2902-2905.	4.7	11

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127	InGaN Metal-Semiconductor-Metal Photodetectors With Aluminum Nitride Cap Layers. IEEE Journal of Quantum Electronics, 2011, 47, 1107-1112.	1.9	11
128	Magnetooptical Effects in Wave Properties for a Semiconductor Photonic Crystal at Near-Infrared. IEEE Photonics Journal, 2012, 4, 903-911.	2.0	11
129	$\frac{1}{m} Ga_{2}(m O)_{3}$ Nanowires-Based Humidity Sensors Prepared on GaN/Sapphire Substrate. IEEE Sensors Journal, 2013, 13, 4891-4896.	4.7	11
130	Numerical Simulation of GaN-Based LEDs With Chirped Multiquantum Barrier Structure. IEEE Journal of Quantum Electronics, 2013, 49, 436-442.	1.9	11
131	Electron field emission enhancement of hybrid Cu/CuO nanowires fabricated by rapid thermal reduction of CuO nanowires. RSC Advances, 2015, 5, 54220-54224.	3.6	11
132	Two-bit-per-cell resistive switching memory device with a Ti/MgZnO/Pt structure. RSC Advances, 2015, 5, 88166-88170.	3.6	11
133	Nitride-Based ultraviolet metal-semiconductor-metal photodetectors with a low-temperature GaN layer. Journal of Electronic Materials, 2003, 32, 400-402.	2.2	10
134	Deposition of SiO[sub 2] layers on 4H–SiC by photochemical vapor deposition. Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena, 2003, 21, 329.	1.6	10
135	InGaN–GaN MQW Metal–Semiconductor–Metal Photodiodes With Semi-Insulating Mg-Doped GaN Cap Layers. IEEE Photonics Technology Letters, 2007, 19, 846-848.	2.5	10
136	AlGaInP LEDs Prepared by Contact-Transferred and Mask-Embedded Lithography. IEEE Journal of Quantum Electronics, 2010, 46, 1834-1839.	1.9	10
137	AlGaInP-Based LEDs With a $mp^{+}\$ -GaP Window Layer and a Thermally Annealed ITO Contact. IEEE Journal of Quantum Electronics, 2011, 47, 803-809.	1.9	10
138	Influence of Weight Ratio of Poly(4-vinylphenol) Insulator on Electronic Properties of InGaZnO Thin-Film Transistor. Journal of Nanomaterials, 2012, 2012, 1-7.	2.7	10
139	Impact of oxygen annealing on high-k gate stack defects characterized by random telegraph noise. Applied Physics Letters, 2012, 101, 122105.	3.3	10
140	Low-Frequency Noise Characteristics of GaN Schottky Barrier Photodetectors Prepared With Nickel Annealing. IEEE Sensors Journal, 2012, 12, 2824-2829.	4.7	10
141	Dislocation reduction through nucleation and growth selectivity of metal-organic chemical vapor deposition GaN. Journal of Applied Physics, 2013, 113, 144908.	2.5	10
142	Stability Improvement of Nitrogen Doping on IGO TFTs under Positive Gate Bias Stress and Hysteresis Test. ECS Journal of Solid State Science and Technology, 2019, 8, Q3034-Q3040.	1.8	10
143	InGaN/GaN multiple quantum well green light-emitting diodes prepared by temperature ramping. Journal of Electronic Materials, 2003, 32, 419-422.	2.2	9
144	Low interface state density AlGaN/GaN MOSHFETs with photochemical vapor deposition SiO2 layers. Physica Status Solidi C: Current Topics in Solid State Physics, 2003, 0, 2355-2359.	0.8	9

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145	GaN Schottky Barrier Photodetectors. IEEE Sensors Journal, 2010, 10, 1609-1614.	4.7	9
146	GaN-Based Power Flip-Chip LEDs With an Internal ESD Protection Diode on Cu Sub-Mount. IEEE Transactions on Advanced Packaging, 2010, 33, 433-437.	1.6	9
147	GaN-Based LEDs With Air Voids Prepared by One-Step MOCVD Growth. Journal of Lightwave Technology, 2011, 29, 2831-2835.	4.6	9
148	GaN-Based LEDs With Sapphire Debris Removed by Phosphoric Etching. IEEE Transactions on Components, Packaging and Manufacturing Technology, 2012, 2, 349-353.	2.5	9
149	AlGaInP-Based LEDs With AuBe-Diffused AZO/GaP Current Spreading Layer. IEEE Journal of Quantum Electronics, 2013, 49, 846-851.	1.9	9
150	Enhanced Field Emission of ${m TiO}_{2}$ Nanowires With UV Illumination. IEEE Electron Device Letters, 2014, 35, 123-125.	3.9	9
151	Failure Mechanism for GaN-Based High-Voltage Light-Emitting Diodes. IEEE Photonics Technology Letters, 2014, 26, 1073-1076.	2.5	9
152	Ultimate Aims and Prospects of Inventions. Inventions, 2016, 1, 1-2.	2.5	9
153	High Stability Flexible Deep-UV Detector Based on All-Oxide Heteroepitaxial Junction. ACS Applied Electronic Materials, 2022, 4, 3099-3106.	4.3	9
154	A Ku-band four-stage temperature compensated PHEMT MMIC power amplifier. Microwave and Optical Technology Letters, 2005, 44, 480-485.	1.4	8
155	Dependence of DC Parameters on Layout and Low-Frequency Noise Behavior in Strained-Si nMOSFETs Fabricated by Stress-Memorization Technique. IEEE Electron Device Letters, 2010, 31, 500-502.	3.9	8
156	\${m TiO}_{2}\$ Nanowires UV Photodetectors With Ir Schottky Contacts. IEEE Photonics Technology Letters, 2012, 24, 1584-1586.	2.5	8
157	GaN-Based LEDs With Omnidirectional Metal Underneath an Insulating \${m SiO}_{2}\$ Layer. IEEE Photonics Technology Letters, 2012, 24, 815-817.	2.5	8
158	Chemical Oxide Interfacial Layer for the High-\$k\$-Last/Gate-Last Integration Scheme. IEEE Electron Device Letters, 2012, 33, 946-948.	3.9	8
159	Tunable Multichannel Filter in a Photonic Crystal Containing Semiconductor Photonic Quantum Well. IEEE Photonics Journal, 2012, 4, 283-290.	2.0	8
160	Investigation of zinc-tin-oxide thin-film transistors with varying SnO2 contents. Electronic Materials Letters, 2014, 10, 89-94.	2.2	8
161	GaN-Based LEDs With Rough Surface and Selective KOH Etching. Journal of Display Technology, 2014, 10, 27-32.	1.2	8
162	Synthesis of In <sub>2</sub> O <sub>3</sub> Nanowires and Their Gas Sensing Properties. IEEE Sensors Journal, 2016, 16, 5850-5855.	4.7	8

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